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In re application of :
Sumio IIJIMA et al. : **Confirmation No. 4026**
Serial No. 10/521,575 : **Mail Stop: OFFICE OF INITIAL
PATENT EXAMINATION'S FILING
RECEIPT CORRECTIONS**
Filed January 18, 2005 : Attorney Docket No. 2005_0065A

STRUCTURES SELECTING METHOD FOR
CARBON NANOTUBES BY LIGHT
IRRADIATION

REQUEST FOR CORRECTED FILING RECEIPT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

A corrected filing receipt is requested in the above-referenced case. A copy of the original filing receipt is enclosed, with the changes noted thereon.

Expedited issuance of the corrected filing receipt is respectfully requested.

Respectfully submitted,

Sumio IIJIMA et al.

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September 14, 2005



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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/521,575	07/20/2005	3726	1030	2005_0065A	3	6	1

CONFIRMATION NO. 4026

FILING RECEIPT



OC000000016925799

513

WENDEROTH, LIND & PONACK, L.L.P.
2033 K STREET N. W.
SUITE 800
WASHINGTON, DC 20006-1021

Date Mailed: 09/08/2005

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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Power of Attorney: The patent practitioners associated with Customer Number 513.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/04182 04/01/2003

Foreign Applications

JAPAN 2003-000718 01/06/2003

Projected Publication Date: To Be Determined - pending completion of Security Review

Non-Publication Request: No

Early Publication Request: No

Title

STRUCTURES SELECTING METHOD FOR CARBON NANOTUBES BY LIGHT IRRADIATION
~~Method of selecting structure of carbon nanotube through photoirradiation~~

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WENDEROTH, LIND & PONACK

Preliminary Class

029

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